

**NATIONAL PHASE  
UTILITY APPLICATION**  
**Transmittal to the (DO/EO/US)**  
**Under 35 USC 371**

Attorney Docket No.: SHIGA7.041APC  
 First Named Inventor: Yasuo Masuda **10/564453**  
 Int'l Application No.: PCT/JP2004/010434  
 Int'l Filing Date: July 15, 2004  
 Priority Date Claimed: July 16, 2003  
 Title: POSITIVE PHOTORESIST COMPOSITION AND  
 METHOD OF FORMING RESIST PATTERN  
 Express Mail Label No.: EV718232874US

**Direct all correspondence to Customer No.: 20995**

Date: January 12, 2006  
 Page 1 of 3

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Yasuo Masuda                            2. Toshiki Okui

**APPLICATION ELEMENTS:**

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
  - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

**OTHER APPLICATION PARTS:**

- (X) Preliminary Amendment in 6 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
  - (X) Listing 13 references.
  - (X) Enclosing 9 references.
- (X) Cover page of PCT publication WO 2005/007718 A1.
- (X) International Search Report and Written Opinion.
- (X) Application Data Sheet in 2 pages.

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<b>AP20040716 12 JAN 2006</b>	
<b>Date: January 12, 2006</b> <b>Page 2 of 3</b>	

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**FILING FEES:**

<b>FEES CALCULATION</b>				
<b>FEES TYPE &amp; DETERMINATION</b>		<b>LARGE FEE</b>	<b>CALCULATION</b>	<b>TOTAL</b>
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) ( <i>enter one in TOTAL column</i> )				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1640 (\$0)		
(2) USPTO was the ISA (noncompliant claims)		1641 (\$100)		\$400
(3) Foreign Search Report Enclosed		1642 (\$400)		
(4) No Search Report Enclosed		1632 (\$500)		
Examination Fee under 1.492(c) ( <i>enter one in TOTAL column</i> )				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1643 (\$0)		\$200
(2) Non US IPEA or Noncompliant Claims		1633 (\$200)		
Excess Claims	4 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	2 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 =	\$0
Late English Translation		1618 (\$130)		
Assignment		8021 (\$40)	1 x 40 =	\$40
			<b>TOTAL FEE DUE</b>	<b>\$940</b>
<b>TOTAL FEE PAID (If Different Than Fee Due)</b>				\$

(X) A check in the amount of \$940 to cover the Total Fee Due is enclosed.

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The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.



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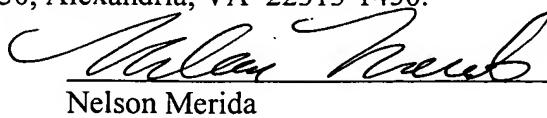
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**Attorney Docket No.** : SHIGA7.041APC  
**Applicant(s)** : Masuda et al.  
**For** : POSITIVE PHOTORESIST COMPOSITION  
AND METHOD OF FORMING RESIST  
PATTERN  
**Attorney** : Daniel E. Altman  
**"Express Mail" Label No.:** EV718232874US  
**Date of Deposit** : January 12, 2006 **EV718232874US**)

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 51 pages; Preliminary Amendment in 6 pages; Application Data Sheet in 2 pages; Cover sheet of PCT publication; signed Declaration and Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; PCT/IB/308; International Search Report and Written Opinion; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 9 references; Check for Filing Fee; Return Prepaid Postcard

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